SHANTANU KALLAKURI

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Expertise: (in)organic synthesis, self-assembly (hierarchical/lipid/directed/modular), thin-films, quantum-dots, Cvd, Ald, Rie, nanomotors, ML/AI, python, lammps, gamess, atomic design, spin QCA, spintronics, click-chem, magic-size clusters

EDUCATION

Cornell University

Ithaca, NY

M.S. with Thesis in Materials Science and Engineering, GPA: 3.9/4

Aug. 2018 - May 2021

- Advisors: Prof. Richard Robinson and Prof. Tobias Hanrath
- Thesis: Development of multiscale hierarchical structures from nanocluster mesophases (10.7298/x221-2n24)
 - a) Developed a 1-pot synthesis of functional quantum dot magic-sized nanocrystals (QD MSNC) that hierarchically self-assemble into a biomimetic mesophase akin to DNA/collagen giving 99.9% pure QD thin-films and helical fibers
 - b) This work is first-of-a-kind since the QDs and these thin-films:
 - i) Span 6-7 orders in magnitude individual qd (nm) to thin-films (cm) that scalably inherit atomic properties
 - ii) Demonstrated a general path to various chemistries with huge improvement over today's hot-injection synthesis
 - iii) Allowed exploration of a larger, softer phase space than one offered by small molecules or bulk materials
 - iv) Ensured consistent shape (<6% monodisperse), were electrically and magnetically tunable, and optically chiral
 - v) Enabled transparent films that could be studied using simple laser-diffraction
 - c) Project work published in Nature Materials (10.1038/s41563-022-01223-3)

Birla Institute of Technology & Science (BITS) Pilani

Pilani, India

Dual degree - B.E. in Chemical Engineering and M.Sc. in Chemistry

Aug. 2010 - July 2015

- Thesis: Bi-conjugated aromatic Porphyrin and Sapphyrin macro-cycles for Dye-sensitized solar cells
- Advisor: Prof. Giribabu Lingamallu, IICT (Indian Institute of Chemical Technology), CSIR
- Award: Ranked department 3rd in the four-year Chemical engineering programme with a major GPA of 9.1/10

EXPERIENCE

Applied Materials Inc.

Santa Clara, CA

Senior Process Engineer, Semiconductor Products Group

Sept. 2021 - Present

- AMAT is the world's largest semiconductor equipment maker & Gate-all-around (GAA) transistors are cornerstones of today's logic and memory applications in advanced-node (n+2, sub-1nm & beyond) PC/AI microprocessor chips
- As Process owner for the Olympia line of machines, AMAT's primary PEALD product (Plasma-enhanced atomic layer deposition), I work in a leading capacity to develop process/chemistry for upcoming gate-all-around devices
- In this role, I have executed multiple IP-covered projects directly enabling 8-figure dollar AMAT product sales and process development for sub-2nm nodes, 3D-DRAM, 3D-NAND, along with 4 granted patents

Process Engineering Co-op Intern (Mid-thesis)

Sept. 2019 - Sept. 2020

- Developed a PECVD & an RIE method for graded-deposition & variable-depth ion etch of dielectrics (SiN_x, SiO_x)
- This enabled selective and directional plasma process on glass for optical applications (AR waveguides, gratings)
- The project led to 2 patents (Both published & pending), an award, and a cash prize for excellence at work

Massachusetts Institute of Technology

Cambridge, MA

Research Assistant, Julia Ortony lab, Dept. of materials science and engineering

Mar. 2017 - Aug. 2017

- Contributed to ideation/synthesis of self-assembling aramid amphiphiles to extract heavy-metals from groundwater
- This work was accepted for the MRS Fall Meet, 2017, Boston, MA, and served as the initial proto-type for future work continued in the following paper in *Nature Nanotechnology* (Doi:10.1038/s41565-020-00840-w)

Harvard Medical School

Cambridge, MA

Research Assistant, Hadi Shafiee Lab, Division of engineering for medicine

Aug. 2016 - Feb. 2017

- $\bullet \ \ Designed \ \& \ synthesized \ a \ catalytic \ Janus \ Pt/Au \ nanomotor \ system \ for \ cheap \ HIV/Zika \ microfluidic \ diagnostics$
- Used Thiol chemistry, PCR, Loop-mediated isothermal DNA amplification (LAMP), & particle velocimetry. The microchip is 99% accurate and has been published in ACS nano and Nature communications

Nature Materials, 21(5): 518-525 (2022): "Multiscale hierarchical structures from a nanocluster mesophase" H. Han, S. Kallakuri, Y. Yao, C. B. Williamson, D. R. Nevers, B. H. Savitzky, R. S. Skye, M. Xu, O. Voznyy, J. Dshemuchadse, L. F. Kourkoutis, S. J. Weinstein, T. Hanrath, R. D. Robinson

Nature Communications, 9(1): 4282 (2018): "DNA-engineered micromotors powered by metal nanoparticles for motion-based cellphone diagnostics" M. S. Draz, K. M. Kochehbyoki, A. Vasan, D. Battalapalli, A. Sreeram, M. K. Kanakasabapathy, S. Kallakuri, A. Tsibris, D. R. Kuritzkes, H. Shafiee

ACS Nano, 12(6): 5709-5718 (2018): "Motion-based immunological detection of Zika Virus using Pt-nanomotors and a cellphone" M. S. Draz, N. K. Lakshminaraasimulu, S. Krishnakumar, D. Battalapalli, A. Vasan, M. K. Kanakasabapathy, A. Sreeram, S. Kallakuri, P. Thirumalaraju, Y. Li, S. Hua, X. G. Yu, D. R. Kuritzkes, H. Shafiee

Functionalized engineering materials & their applications, 1(1):117-124 (2016): "Synthesis and characterization of templated Polyanilines: A new class of polymeric materials" J. Avusula, S. Kallakuri, J. Subbalakshmi

PATENTS

US11956978B2 | Techniques and device structure based upon directional seeding and selective deposition (April 2024) M. A. Zeeshan, K. Chan, S. Kallakuri, S. Varghese. This IP describes a process to selectively, angularly deposit metals & dielectrics on SiN_x vs SiO_x vs Si, the three most common substrates in semiconductor microchip fabrication

US20240040808A1 | Techniques and device structure based upon directional seeding and selective deposition (February 2024) S. Varghese, M. A. Zeeshan, S. Kallakuri, K. Chan. Split patent encompassing parts of the above project idea

US11749564B2 | Techniques for void-free material depositions (September 2023)

M. A. Zeeshan, K. Chan, S. Kallakuri, S. Varghese, J. Hautala. This IP covers a foundational way to void-free deposit metal for Buried Wordline fill application (BWL) in leading-node transistors since voids raise chip operating resistance

US11404314B2 | Metal line patterning (August 2022)

S. Varghese, M. A. Zeeshan, S. Kallakuri, K. Chan. This method describes a process-flow for selective fin patterning through deposition/etch steps using Plasma-enhanced CVD and/or ALD for transistor Wordline and Bitline application

US20220100078A1 | Devices and methods for variable etch depths (Pending)

M. A. Zeeshan, R. Bandy, P. F. Kurunczi, S. Kallakuri, T. Soldi, J. C. Olson. This work covers a process-flow crucial to plasma etch processing of waveguides and gratings on optical glass (Various glass types) for Augmented Reality

US20220119955A1 | Techniques for variable deposition profiles (Abandoned by us)

M. A. Zeeshan, S. Kallakuri, J. C. Olson. This IP modulates refractive index for AR. Abandoned it due to commercials

CERTIFICATIONS

Stanford: Harnessing the Power of AI/ML to Address New Engineering Challenges

Successfully completed a semester-long comprehensive 15-week program on ML and implemented CNNs, kNNs, decision trees, SVM, linear regression, logistic regression and a final project applying CNNs for semiconductor defect classification

AWARDS

Awards: Applied Materials performance award | T.I.M.E undergraduate engineering & management scholarship Accolades: Secured Bronze representing my state & university in Carom, Soccer at national sports fests BOSM, SPREE

TEACHING / OUTREACH

Teaching assistantships:- ENGRG1160 Intro to engg. | MSE5860 Atomic structure | MSE4330 Energy materials

Outreach:- Expanding your horizons: Mentoring 7th - 10th grade students as an EYH mentor since July 2019

Volunteering: Regular organizer since 2018 at Asha: a non-profit that raises funds for underprivileged students in rural India through concerts, fests, student-cooked dinners & at Spicmacay: a non-profit popularizing Indian classical music

SKILLS

Lab: (in)organic synthesis, self-assembly, quantum-dot nanocrystals, spinels, amphiphiles, donor-acceptors, porphyrins Techniques: PEALD, PECVD, RIE, UV-Vis, XRD, NMR, FTIR, SAXS, OES, Ellipsometry, SRIM, Optical diffraction Simulation & modelling: LAMMPS & MD, GAMESS (Basic), Blender, Cinema4D, Solidworks, Ansys Fluent ML & AI: Convolutional neural networks, support vector regression, logistic & linear regression, kNNs, decision trees Programming: Python (proficient), Java (proficient), MatLab, C/C++, VBA, SQL, JavaScript, HTML/CSS Statistics & libraries: Pandas, NumPy, Scikit-learn, Tensorflow, SciPy, Seaborn, Matplotlib, SAS (JMP), DOE